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| APPLICATION NUMBER | FILING or 371(G)<br>DATE | GRP ART UNIT | FIL FEE REC'D | ATTY.DOCKET.NO | TOT CLAIMS | IND CLAIMS |
|--------------------|--------------------------|--------------|---------------|----------------|------------|------------|
| 10/589,762         | 08/17/2006               | 1714         | 900           | 12477/12       | 17         | 2          |

## CONFIRMATION NO. 2280

23838  
KENYON & KENYON LLP  
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WASHINGTON, DC20005

## FILING RECEIPT

Date Mailed: 03/16/2007

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## Applicant(s)

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**Power of Attorney:** The patent practitioners associated with Customer Number 23838

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP05/02716 02/21/2005

## Foreign Applications

JAPAN 2004-045665 02/23/2004  
JAPAN 2004-045666 02/23/2004  
JAPAN 2004-058805 03/03/2004  
JAPAN 2004-058807 03/03/2004  
JAPAN 2004-279618 09/27/2004  
JAPAN 2004-279619 09/27/2004

If Required, Foreign Filing License Granted: 03/05/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is  
**US10/589,762**

Projected Publication Date: 06/14/2007

Non-Publication Request: No

**Early Publication Request: No**

**Title**

Porous film, process for producing the same, and lithium-ion secondary cell made with the same

**Preliminary Class**

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